	Hits	Search Text	DBs
65	18	(((resist or photoresist) near19 (mask or pattern)) same (ash$4 or imping$4 or irradiat$4 or introduc$4 or expos$4) same (oxygen or ozone)) and (((photoresist or resist) near5 pattern near22 (undercut$4 or overhang)) same (shape or trapezoid or slant$4 or configuration))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
67	8	(((resist or photoresist) near19 (mask or pattern)) same (ash$4 or imping$4 or irradiat$4 or introduc$4 or expos$4) same (oxygen or ozone)) and (((photoresist or resist) near5 pattern near22 (undercut$4 or overhang or terrace))) and liftoff	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB